

**MICROELECTRONICS & ANALOG VLSI DESIGN  
(ECEN 3103)**

**Time Allotted : 3 hrs**

**Full Marks : 70**

***Figures out of the right margin indicate full marks.***

***Candidates are required to answer Group A and  
any 5 (five) from Group B to E, taking at least one from each group.***

***Candidates are required to give answer in their own words as far as practicable.***

**Group – A  
(Multiple Choice Type Questions)**

1. Choose the correct alternative for the following: **10 × 1 = 10**
- (i) The low frequency MOS series capacitance in the strong inversion region is
    - (a) depletion layer capacitance and the insulator capacitance in series
    - (b) depletion layer capacitance
    - (c) insulator capacitance
    - (d) depletion layer capacitance and the insulator capacitance in parallel.
  - (ii) According to Moore's law, the dimensions of a MOS device are reduced with every technology node roughly by
    - (a) 20%                      (b) 50%                      (c) 70%                      (d) 80%.
  - (iii) The threshold voltage in short channel MOSFETs \_\_\_\_\_
    - (a) shifts towards the higher voltage                      (b) shifts towards the lower voltage
    - (c) remains same                      (d) none of the above.
  - (iv) Value of 'lambda' in 180nm technology node is
    - (a) 360nm                      (b) 180nm                      (c) 90nm                      (d) 45nm.
  - (v) Sputtering is a \_\_\_\_\_ process
    - (a) physical                      (b) chemical
    - (c) mechanical                      (d) none of the above.
  - (vi) The performance of a current source/sink may be improved by
    - (a) reducing  $V_{min}$  and output resistance
    - (b) increasing  $V_{min}$  and output resistance
    - (c) reducing  $V_{min}$  and increasing output resistance
    - (d) increasing  $V_{min}$  and reducing output resistance.
  - (vii) Photo resist is a \_\_\_\_\_ compound
    - (a) radiation sensitive                      (b) radiation insensitive
    - (c) radiative                      (d) non-radiative.

- (viii) The performance of a current mirror circuit depends on  
(a) channel length modulation (b) aspect ratio  
(c)  $V_{th}$  (d) all of the above.
- (ix) Switched capacitor circuit realizes  
(a) resistance (b) capacitance  
(c) inductance (d) current source.
- (x) CMRR for a perfectly matched Differential Amplifier circuit  
(a) one (b) zero (c) infinite (d) ten.

**Group – B**

2. (a) Define the threshold voltage of a MOSFET. [(CO1)(Remember/LOCQ)]  
(b) Explain with the help of band diagram the condition of inversion in an n-channel MOSFET. [(CO2)(Understand/LOCQ)]  
(c) Show with appropriate diagram how the capacitance of a MOS structure changes with the applied gate voltage. [(CO2)(Analyze/IOCQ)]  
**2 + 5 + 5 = 12**
3. (a) Show the impact of channel length modulation on the drain current characteristics of enhancement type MOSFET. [(CO1)(Apply/IOCQ)]  
(b) What are short channel effects in MOSFETs? [(CO1)(Remember/LOCQ)]  
(c) Discuss any one short channel effect in a MOSFET. [(CO1)(Analyze/IOCQ)]  
**5 + 2 + 5 = 12**

**Group – C**

4. (a) Illustrate with a flow diagram, the steps of fabrication of an nMOS. [(CO2) (Remember/LOCQ)]  
(b) Differentiate between dry and wet oxidation. [(CO2) (Understand/LOCQ)]  
**6 + 6 = 12**
5. (a) What is photolithography? [(CO2)(Remember/LOCQ)]  
(b) Differentiate between positive and negative photoresist. [(CO2)(Understand/LOCQ)]  
(c) Show the steps of pattern transfer using a positive photoresist. [(CO2)(Apply/IOCQ)]  
**2 + 4 + 6 = 12**

**Group – D**

6. (a) Draw the small signal equivalent circuit model of an nmos at low frequency. [(CO3) (Apply/IOCQ)]  
(b) Mention the advantage of using a CMOS switch over a single MOS switch. [(CO3) (Understand/LOCQ)]  
(c) Show how a MOS may be used as a diode. [(CO3)(Apply/IOCQ)]  
**4 + 2 + 6 = 12**

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7. (a) Draw a current mirror circuit using pmos. [(CO3)(Apply/IOCQ)]  
 (b) Derive an expression for the output current neglecting the channel length modulation phenomenon. [(CO3) (Create /HOCQ)]  
 (c) Discuss about the non-idealities that may affect the output current. [(CO3)(Analyze/IOCQ)]

**4 + 5 + 3 = 12****Group – E**

8. (a) Obtain the small signal equivalent circuit model of an active pmos load inverter. [(CO4)(Apply/IOCQ)]  
 (b) Find out its voltage gain and the output resistance. [(CO4)(Create/HOCQ)]

**6 + 6 = 12**

9. (a) Consider a MOS differential amplifier with a differential input signal applied in a complementary manner. Show that the gain of the amplifier is doubled when the output is taken differentially and not in a single-ended fashion. [(CO4)(Create/HOCQ)]  
 (b) Define CMRR. What is its ideal value? [(CO4) (Remember/LOCQ)]

**9 + 3 = 12**


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Cognition Level	LOCQ	IOCQ	HOCQ
Percentage distribution	33.33%	45.83%	20.83%

**Course Outcome (CO):**

After the completion of the course students will be able to

1. Basics of microelectronics and VLSI design
2. Types of MOS, IC manufacturing Process - the steps
3. Analog VLSI circuits – the intricacies
4. Important Circuits like OP AMP and their analysis

\*LOCQ: Lower Order Cognitive Question; IOCQ: Intermediate Order Cognitive Question;  
 HOCQ: Higher Order Cognitive Question

Department & Section	Submission Link
ECE - BACKLOG	<a href="https://classroom.google.com/c/NDY1NzMyNTU0NTk5?cjc=ynin37y">https://classroom.google.com/c/NDY1NzMyNTU0NTk5?cjc=ynin37y</a>